STNOUSPATFULL]

(FILE 'HOME' ENTERED AT 15:02:51 ON 22 NOV 2006)

	FILE 'USPA'	rfull' Entered at 15:03:04 ON 22 NOV 2006
L1		S ?POLISH? OR CHEMIMEC? OR PLANRAIZ? OR LAP? OR GRIND? OR ABRAD
L2		S SILICA OR SIO2 OR SI203 OR SILICON(W) (DIOXIDE OR MONOXIDE)
L3		S CA OR CALCIUM OR BA OR BARIUM OR SR OR STRONTIUM
L4		S L1(P) L2(P) L3
L5		S L2 (5A) FUM?
L6		S L4 (P) L5
L7		S L6 (P) PH
L8		S L6 NOT L7
L9		S L8 AND (?POLISH? OR CHEMIMEC? OR PLANRAIZ? OR LAP? OR GRIND?
L10		S L8 NOT L9
пто	101	SET HIGH OFF
L11	21	S L10 AND (SEMICONDUCT? OR WAFER? OR CHIP#)
птт	21	SET HIGH ON
L12	21	S L10 AND L11
L13	416	S L4(P)PH
		SET HIGH OFF
L14	105	S L13 AND (SEMICONDUCT? OR WAFER? OR CHIP#)
		SET HIGH ON
L15	105	S L13 AND L14
L16	103	S L15 NOT (L7 OR L9 OR L12)
L17	128	S L13(P) (OXID? OR PEROXIDE OR H2O2)
L18	36	S L16 AND L17
L19	67	S L16 NOT L18
L20	101238	S (?POLISH? OR CHEMIMEC? OR PLANRAIZ? OR LAP? OR GRIND? OR ABRA
L21	70790	S (SILICA OR SIO2 OR SI203 OR SILICON(W) (DIOXIDE OR MONOXIDE))/
L22	98347	S (CA OR CALCIUM OR BA OR BARIUM OR SR OR STRONTIUM)/CLM
L23	1325	S L20 AND L21 AND L22
L24	96	S L23 AND FUMED/CLM
		SET HIGH OFF
L25	24	S L24 AND (SEMICONDUCT? OR WAFER? OR CHIP#)
		SET HIGH ON
L26	24	S L24 AND L25
L27	15	S L26 NOT (L7 OR L9 OR L12 OR L17)
L28	9	S L26 NOT L27
L29	1331	S L20 AND (L21 OR FUMED/CLM) AND L22
L30	282	S L29 AND PH/CLM
L31	234	S L30 NOT (L7 OR L9 OR L12 OR L17 OR L26)
		SET HIGH OFF
L32	43	S L31 AND (SEMICONDUCT? OR WAFER? OR CHIP#)
		SET HIGH ON
L33	43	S L31 AND L32